

## С П И С Ъ К

на цитирания на научните трудове на  
**чл.-кор. д-р ГЕОРГИ МИХАЙЛОВ МЛАДЕНОВ**  
от Институт по електроника при БАН

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摘要电子束技术具有高能量密度, 高真空度的优点, 并且能够实现精确控制, 成为目前熔炼提纯 太阳能级多晶硅, 精炼高熔点金属及其合金以及制备高纯特殊钢和超洁净钢的有效手段. 本文在阐述电子束熔炼原理的基础上, 着重对电子束技术在几种高纯材料与合金精炼中的研究与 ...
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